



INFORMATION DISCLOSURE CITATION
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Applicant(s)
Michael J. Scaggs

Filing Date
09/30/2002

Group Art Unit
Unknown

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE
RRB	AA	3,679,863	07/25/1972	Houldcroft et al.	219	121 LM	11/10/1969
↑	AB	3,749,878	07/31/1973	Sullivan et al.	219	121 L	01/19/1971
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						YES	NO
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BG	A. Dupont, et al., "Enhancement of material ablation using 248, 308, 532, 1064 nm laser pulse with a water film on the treated surface," <i>J. Appl. Phys.</i> , Vol. 78, No. 3, 1 August 1995, pp. 2022-2028.
BH	S. Zhu, et al., "Laser ablation of solid substrates in a water confined environment," <i>Applied Physics Letters</i> , Vol. 79, No. 9, 27 August 2001, pp. 1396-1398.

Examiner

R. Burles

Date Considered

7-2005 and 3-2006

Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.